

ABSTRACT

To supply a more stable fine bubble liquid to a device. A substrate processing device includes: a first substrate detection unit that detects a substrate in a first module to be used in a first process; a bubble measurement unit that measures a bubble amount in piping, which supplies a fine bubble liquid to a second module to be used in a second process subsequent to the first process, in response to detection of the substrate by the first substrate detection unit; and a control unit that controls the bubble amount in accordance with a measurement result by the bubble measurement unit.

Fig. 2